



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

August 12, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG827601685

LABORATORY GROWN DIAMOND

OVAL BRILLIANT

8.22 X 5.78 X 3.62 MM

1.07 CARAT

D

VVS 2

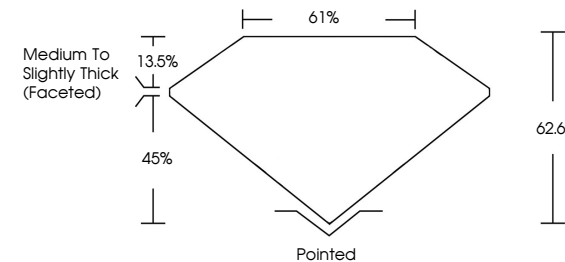
EXCELLENT

EXCELLENT

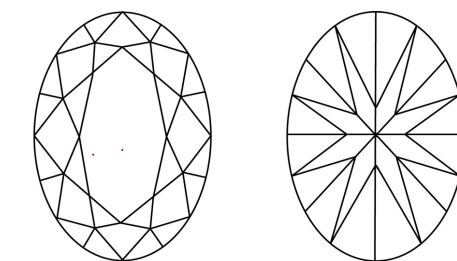
NONE

 LG827601685

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

CLARITY

Sample Image Used



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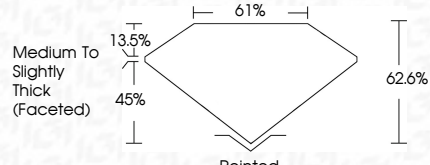
EXCELLENT

EXCELLENT

NONE

 LG827601685

PROPORTIONS



IGI



August 12, 2026

IGI Report No LG827601685

OVAL BRILLIANT

8.22 X 5.78 X 3.62 MM

Carat Weight

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Clarity Grade

Table

Girdle

Medium to Slightly Thick (Faceted)

Pointed

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

1.07 CARAT

D

VVS 2

62.6%

61%

EXCELLENT

EXCELLENT

NONE

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www.igi.org

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